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Quantum Yield Optimization for Semiconductor Photocatalysis Systems

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Design and Build of a Photocatalytic Reactor

Introduction

The utilization of photocatalysis has well-known potential for the degradation of organic contaminants in water purification processes [1]. A continuous flow photocatalytic reactor was developed in order to optimize the quantum yield of titanium dioxide (TiO₂,) a semiconductor material well known for its photocatalytic properties [2]. This photocatalytic reactor was particularly designed for a controlled, variable radiant flux of ultraviolet (UV) light onto a fixed 3-dimensional thin-film catalyst structure. An exploded-view solid model representation of the UV chamber and a transparent view are shown below in Figure 1, parts a) and b) respectively.

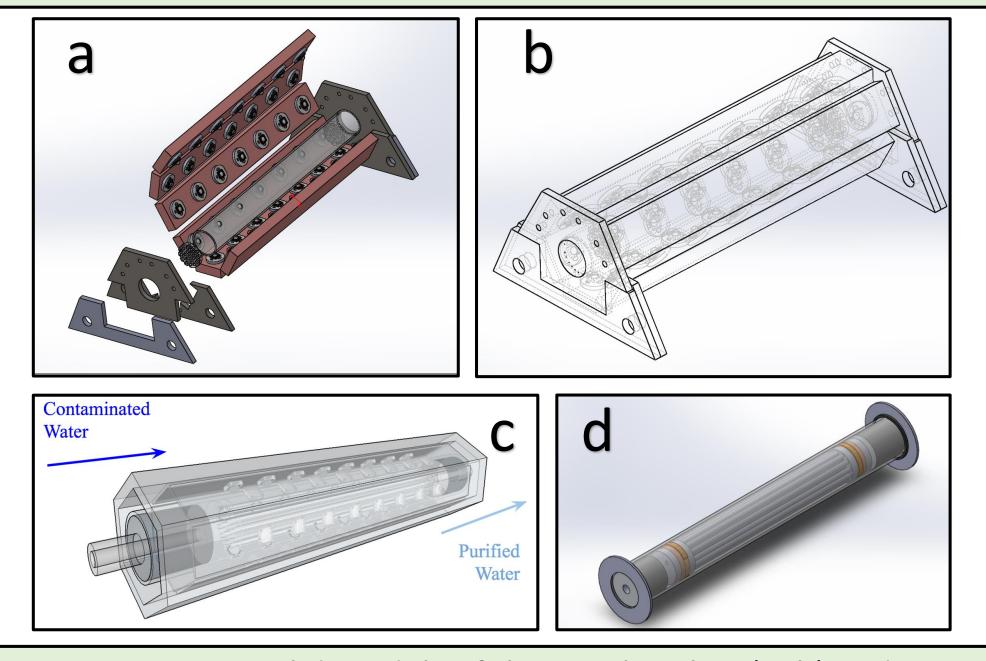


Figure 1. Solid models of the UV chamber (a, b) and the catalyst reactor core (c, d) [3]

Continuous UV radiation excites the photocatalyst, Synthesizing the TiO₂ catalyst onto the quartz substrate is an generating electron-hole pairs that form hydroxyl radicals. important aspect of this work. Prior to catalyst cartridge The design of the reactor includes a variable catalyst syntheses, a material synthesis procedure is to be finalized. A cartridge (shown above in parts c) and d) of Figure 1), sol-gel dipping process is being used to establish a TiO₂ thin allowing multiple catalyst thicknesses, positions, and phases film with the highest catalytic activity. To characterize the to be tested in rapid succession. In having these controlled synthesized films, multiple analytical tools such as scanning variables, this reactor allows for a consistent measurement electron microscopy (SEM) with energy dispersive of contaminant degradation, relating directly to the quantum spectroscopy (EDS), Raman spectroscopy and UV-Vis yield of the catalyst. Results from testing are to be compared spectroscopy were used. to a theoretical model developed to optimize catalyst geometry based on electron-hole pair generation and diffusion processes.

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Reactor Build

There are three parts to this work: UV chamber and control system, catalyst cartridge assembly, and material synthesis. The reactor UV chamber consists of six illumination walls, each with high-powered UV-LEDs mounted within. The intensity of UV exposure to the catalyst is controlled by pulse-widthmodulation on a touchscreen display. Below, Figure 2 shows multiple views of the reactor. 2b) shows the illumination of the UV chamber core, while 2d) shows the reactor core.

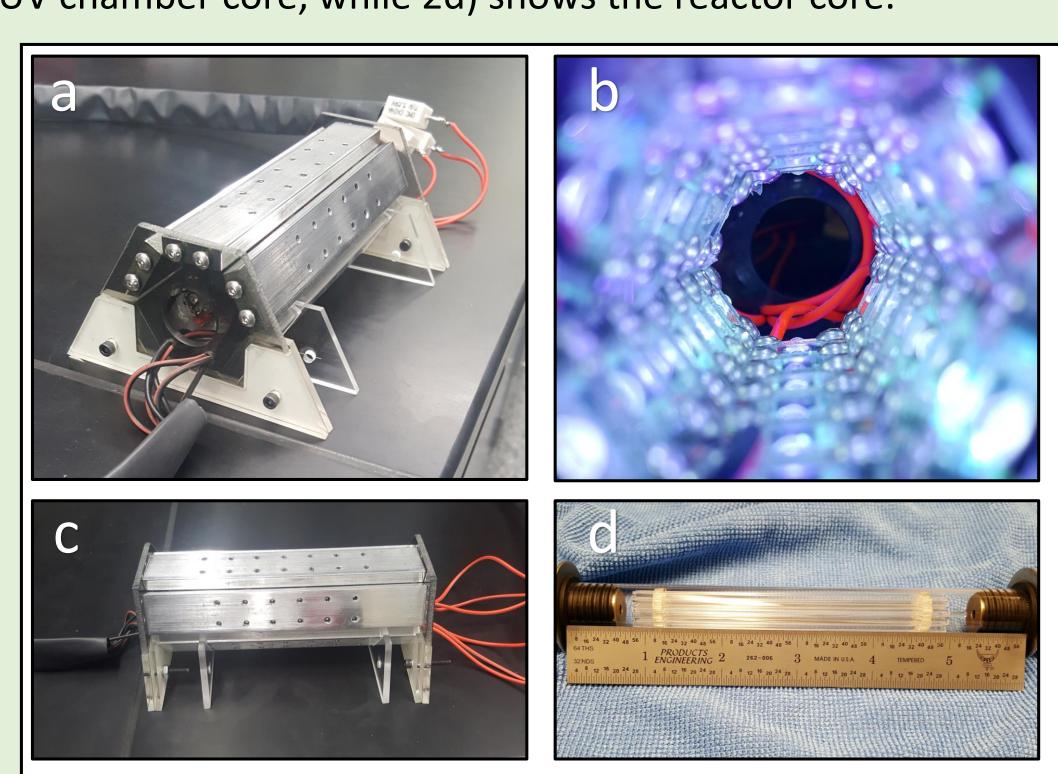
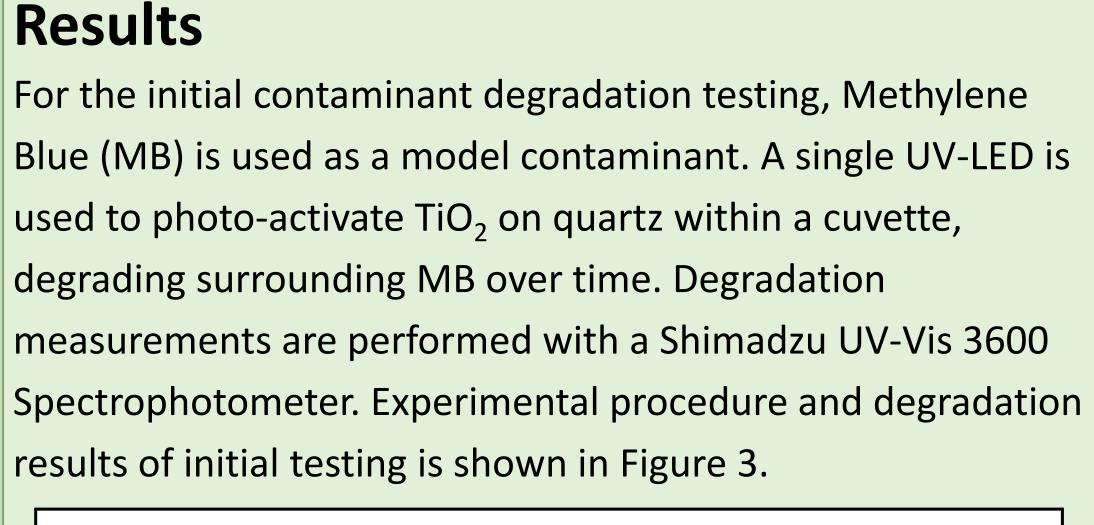


Figure 2. Images of the UV chamber (a-c), and the catalyst reactor core (d).

Material Synthesis





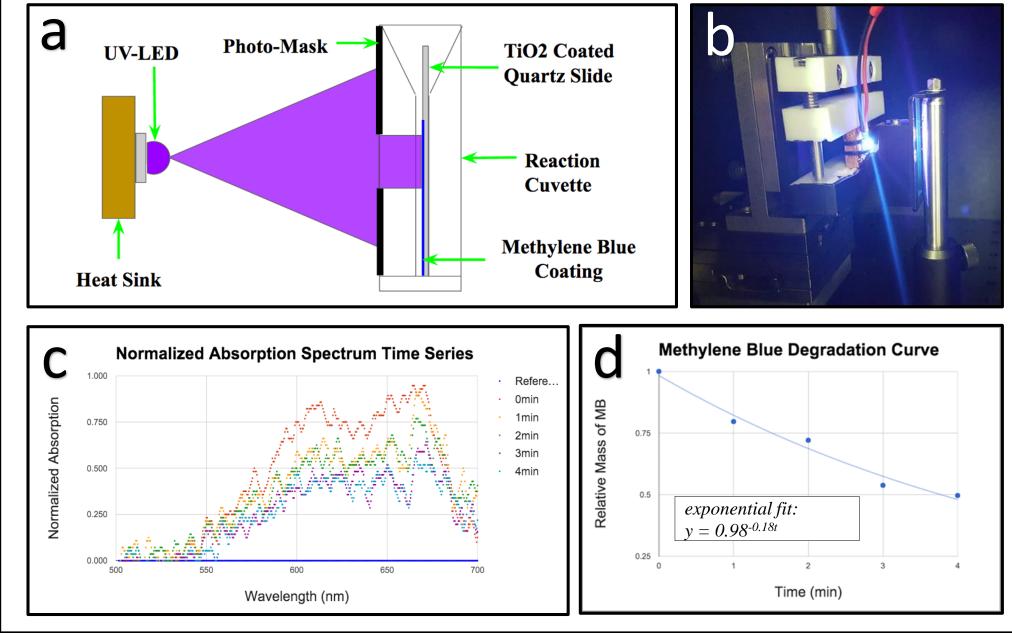


Figure 3. Experimental procedure and depiction for initial catalyst testing is shown in (a) and (b). UV-Vis data shows the degradation of the MB over time in (c) and (d). Depiction and data is from previous testing done by the same group [3].

Future Work

The next steps of this research include the following: finalizing the material synthesis process, establishing the control and degradation measurement systems, and testing the system for continuous flow degradation.

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